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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

application of:

MARTIN WEBER ET AL.

Group Art Unit: 1722

Serial No.: 10/690,415

Examiner: Felisa Carla Hiteshew

Filed: October 21, 2003

For: PROCESS FOR PRODUCING A SILICON SINGLE
CRYSTAL WHICH IS DOPED WITH HIGHLY VOLATILE
FOREIGN SUBSTANCES

Attorney Docket No.: WSAG 0140 PUS

AMENDMENT UNDER 37 C.F.R. § 1.111

Mail Stop Amendment
Commissioner for Patents
U.S. Patent and Trademark Office
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:


In response to the Office Action mailed March 31, 2005, please amend the
above-identified application as follows:

CERTIFICATE OF MAILING UNDER 37 C.F.R. § 1.8

I hereby certify that this paper, including all enclosures referred to herein, is being deposited with the United States Postal Service as first-class mail, postage pre-paid, in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, U.S. Patent and Trademark Office, P.O. Box 1450, Alexandria, VA 22313-1450 on:

June 28, 2005
Date of Deposit

William G. Conger
Name of Person Signing


Signature